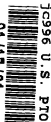


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PATENT

Docket No. JCL A6211

Date: 1-17-2001

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ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231
ATTENTION: APPLICATION BRANCH

Sir:

Transmitted herewith for filing is the patent application of

Inventors: Yun-Kuei Yang, Yi-Ming Chang

For: METHOD OF USING ION IMPLANTATION TO FORM OPENINGS IN AN
INSULATOR

Enclosed are:

- ☒ Specification 14 pages.
- ☒ 6 Sheets of drawings
- ☒ Recordation Form Cover sheet with 2 pages assignment.
- ☐ A certified copy of Taiwan Patent Application No. dated
- ☒ **SIGNED** declaration and power of attorney.
- ☒ Return Prepaid postcard.

CLAIMS AS FILED

FOR	NUMBER FILED					NUMBER EXTRA	RATE	FEE
Basic Fee							\$710.00	\$710.00
Total Claims	19	—	20 =	0	×		\$18.00	\$0.00
Independent Claims	2	—	3 =	0	×		\$80.00	\$0.00
If application contains any multiple dependent claim (s), then add							\$270.00	\$0.00
TOTAL FILING FEE								\$710.00

- ☒ A check in the amount of \$710 cover the filing fee is enclosed.
- ☒ A check in the amount of \$40.00 to cover the assignment recording fee.
- ☒ A duplicate copy of this sheet is enclosed.

Jiawei Huang

Registration No. 43,330

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